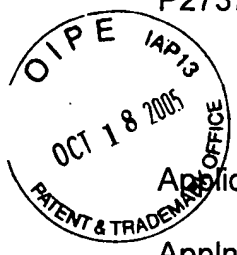


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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants : Dureseti CHIDAMBARRAO, et al.

Group Art Unit: 2814

Appln. No. : 10/605,108

Examiner: PHAM, Long

Filed : September 9, 2003

For : METHOD FOR REDUCED N+ DIFFUSION IN STRAINED SI  
ON SI/GE SUBSTRATE

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Respectfully submitted,  
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